

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

| APPLICATION NO. | FILING DATE | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO. | CONFIRMATION NO. |
|--------------------------|-----------------|----------------------|-------------------------|------------------|
| 10/717,571 | 11/21/2003 | Koji Shigemura | 1670.1020 | 9396 |
| 49455 | 7590 10/18/2005 | | EXAMINER | |
| STEIN, MCEWEN & BUI, LLP | | | WALFORD, NATALIE K | |
| 1400 EYE ST | REET, NW | | ART UNIT | PAPER NUMBER |
| SUITE 300 WASHINGTO | ON, DC 20005 | | 2879 | |
| | · | | DATE MAILED: 10/18/200: | 5 |

Please find below and/or attached an Office communication concerning this application or proceeding.

| | | | EIL |
|--|---|---|-----|
| | Application No. | Applicant(s) | |
| | 10/717,571 | SHIGEMURA, KOJI | |
| Office Action Summary | Examiner | Art Unit | |
| | Natalie K. Walford | 2879 | |
| The MAILING DATE of this communication Period for Reply | appears on the cover sheet w | ith the correspondence address | |
| A SHORTENED STATUTORY PERIOD FOR REWHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CF after SIX (6) MONTHS from the mailing date of this communication - If NO period for reply is specified above, the maximum statutory pour specified period for reply within the set or extended period for reply will, by some any reply received by the Office later than three months after the rearned patent term adjustment. See 37 CFR 1.704(b). | G DATE OF THIS COMMUNI R 1.136(a). In no event, however, may a n. eriod will apply and will expire SIX (6) MO tatute, cause the application to become A | CATION. reply be timely filed NTHS from the mailing date of this communication BANDONED (35 U.S.C. § 133). | |
| Status | | | |
| 1) Responsive to communication(s) filed on 2 | 21 November 2003. | | |
| • | This action is non-final. | | |
| Since this application is in condition for all closed in accordance with the practice und | owance except for formal mat | | ; |
| Disposition of Claims | | , | |
| · _ | tion | | |
| 4) Claim(s) 1-19 is/are pending in the applica 4a) Of the above claim(s) is/are with | | | |
| 5) Claim(s) is/are allowed. | idiawii ilolii colisideration. | | |
| 6) Claim(s) is/are rejected. | | | |
| 7) Claim(s) is/are objected to. | | | |
| 8) Claim(s) <u>1-19</u> are subject to restriction and | /or election requirement. | | |
| Application Papers | | | |
| 9) The specification is objected to by the Exam | miner. | | |
| 10) The drawing(s) filed on is/are: a) | | by the Examiner. | |
| Applicant may not request that any objection to | | | |
| Replacement drawing sheet(s) including the co | | | d). |
| 11)☐ The oath or declaration is objected to by th | · | | |
| Priority under 35 U.S.C. § 119 | | | |
| 12) Acknowledgment is made of a claim for fora) All b) Some * c) None of: | eign priority under 35 U.S.C. | § 119(a)-(d) or (f). | |
| 1. Certified copies of the priority docum | nents have been received. | | |
| 2. Certified copies of the priority docum | nents have been received in A | Application No | |
| 3. Copies of the certified copies of the | priority documents have been | n received in this National Stage | • |
| application from the International Bu | ıreau (PCT Rule 17.2(a)). | | |
| * See the attached detailed Office action for a | a list of the certified copies no | t received. | |
| Attachment(s) | | | |
| 1) Notice of References Cited (PTO-892) | 4) 🔲 Interview | Summary (PTO-413) | |
| 2) Notice of Draftsperson's Patent Drawing Review (PTO-948 | Paper No | (s)/Mail Date | |
| Information Disclosure Statement(s) (PTO-1449 or PTO/S Paper No(s)/Mail Date | B/08) 5) Notice of 6) Other: | Informal Patent Application (PTO-152) | |

DETAILED ACTION

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 1-7, drawn to the deposition mask frame assembly, classified in class 118, subclass 720.
- II. Claims 8-13, drawn to a method of manufacturing a deposition mask frame assembly, classified in class 205, subclass 125.
- III. Claims 14-19, drawn to a method of manufacturing an organic EL device, classified in class 427, subclass 66.

The inventions are distinct, each from the other because of the following reasons:

Inventions I and II or III are related as process and apparatus for its practice.

The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case, the apparatus as claimed can be used to practice another and materially different process such as deposition of phosphorescent materials in cathode ray tube faceplates.

Inventions II and III are related as subcombinations disclosed as usable together in a single combination. The subcombinations are distinct from each other if they are shown to be separately usable. In the instant case, invention II has separate utility such

Art Unit: 2879

as for the electroplating deposition of electrode structures in liquid crystal displays. See

MPEP § 806.05(d).

The inventions are distinct, each from the other because of the following reasons:

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, and because of their recognized divergent subject matter, restriction for examination purposes as indicated is proper.

A telephone call was made to Michael Stein on September 28, 2005 to request an oral election to the above restriction requirement, but did not result in an election being made.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Natalie K. Walford whose telephone number is (571)-272-6012. The examiner can normally be reached on Monday-Friday, 8 AM - 4:30 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimesh Patel can be reached on (571)-272-2457. The fax phone number for the organization where this application or proceeding is assigned is (571)-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

nkw Dalpra

MARICELI SANTIAGO PRIMARY EXAMINER